

## NS6130-10-1049

# COBALT IRON

## Sputtering Target

### Quick Facts

Product	:	Cobalt Iron Sputtering Target
Stock No	:	NS6130-10-1049
Purity	:	99.99%
Molecular Formula	:	CoFe

### Technical Specification

Diameter	Thickness
50.8 mm $\pm$ 1mm	3 mm $\pm$ 0.5mm

CoFe sputtering targets are valuable materials for the production of thin films with specific properties for various applications in the semiconductor and electronics industries. CoFe sputtering targets have a range of properties, including high magnetic anisotropy, excellent soft magnetic properties, and good thermal stability. They are commonly used in the production of magnetic storage media, such as hard disk drives, as well as in the production of other electronic components, such as sensors and actuators.



\* This image is for graphic purposes only and does not represent the actual product.

